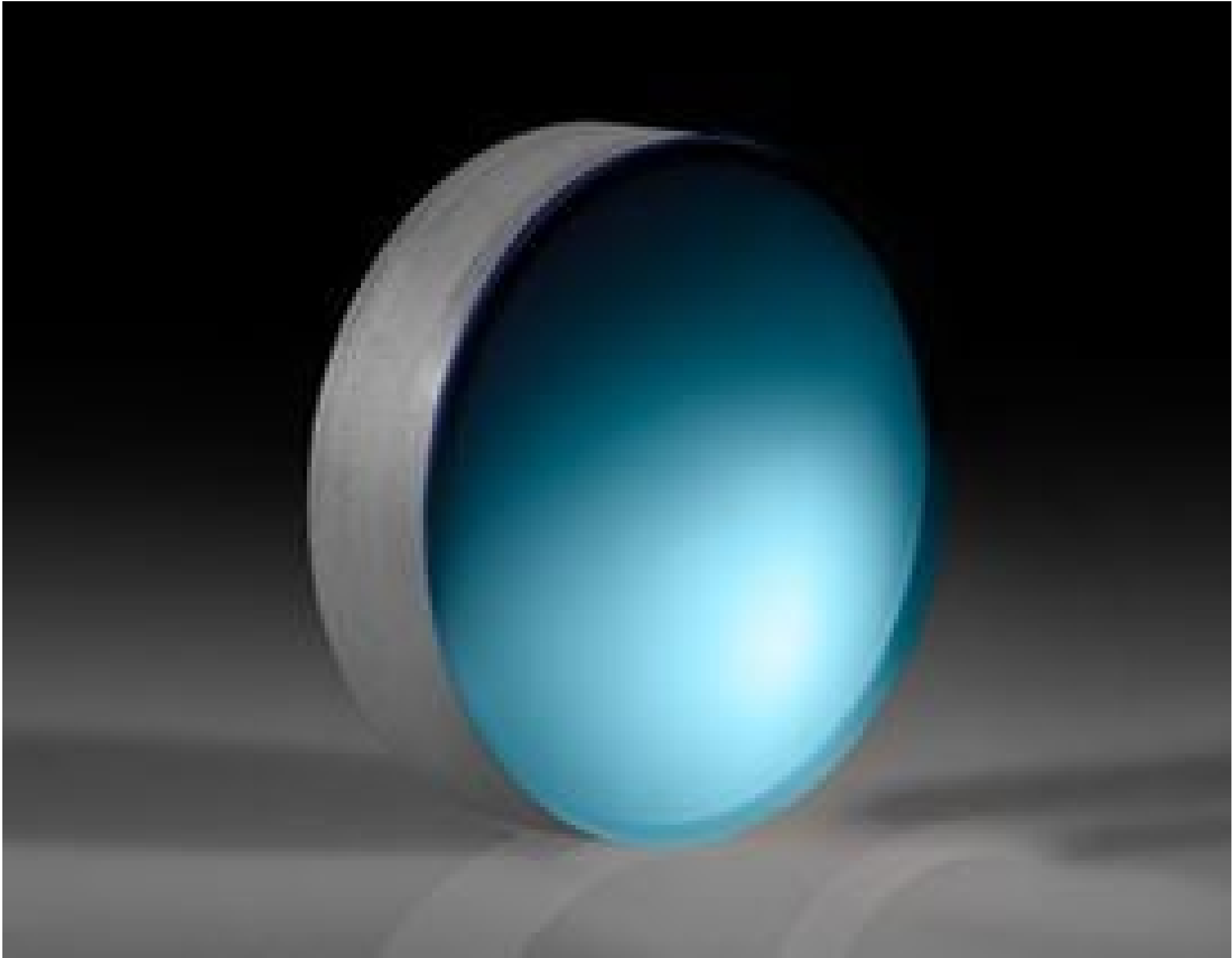


TECHSPEC[®] 600 - 1000nm, 25.4mm Dia. Ultrafast-Enhanced Silver, Silicon, Laser Mirror



Stock #90-192 NEW 4 In Stock

-

1

+

C\$219^{.00}

ADD TO CART

Volume Pricing	
Qty 1+	C\$219.00 each
Need More?	Request Quote

Product Downloads

General	
Flat Mirror	Type:
Physical & Mechanical Properties	
<3	Parallelism (arcmin):
90	Clear Aperture (%):
Commercial Polish	Back Surface:
	Diameter (mm):

25.40 +0.00/-0.10	
6.35 ±0.10	Thickness (mm):
Ground, protective bevel as needed	Edges:
Optical Properties	
40-20	Surface Quality:
Coating Specification: Ravg >99% @ 600 - 1000nm, 0° Rs >99% @ 540 - 1000nm, 45° Rp >98.5% @ ~730 - 870nm, 45°	
0 ±30fs ² @ 600 - 1000nm	GDD Specification:
600 - 1000	Wavelength Range (nm):
λ/10	Surface Flatness (P-V):
Ultrafast-Enhanced Silver	Coating Type:
Ultrafast-Enhanced Silver (600-1000nm)	Coating:
Optical Grade Silicon	Substrate: □
Damage Threshold, Reference: □ 0.3 J/cm ² @ 800nm, 48fs, 1 pulse (typical) 0.16 J/cm ² @ 800nm, 48fs, 100Hz, 1000 pulses (typical)	
Regulatory Compliance	
View	Certificate of Conformance:

Product Details

- Silicon Substrate for Thermally Demanding Ultrafast Setups
- Ideal For Ti:Sapphire- and Yb-Based Ultrafast Laser Systems
- Designed For Ultrafast Pulse Reflection Where Low Dispersion is Critical
- < 30fs² GDD in Target Wavelength Ranges

TECHSPEC® Ultrafast-Enhanced Silver Coated Silicon Laser Mirrors combine a broadband enhanced-silver coating with low group delay dispersion (GDD) for ultrafast pulse applications. These mirrors are designed for systems where maintaining pulse fidelity is critical, and reflectivity and GDD are characterized across the specified wavelength range of 600 – 1000nm or 800 – 1150nm. These silicon substrate mirrors feature higher thermal conductivity than comparable [fused silica substrate mirrors](#), which helps evenly distribute absorbed heat in thermally demanding optical setups. TECHSPEC® Ultrafast-Enhanced Silver Coated Silicon Laser Mirrors are ideal for broadband ultrafast beam delivery where high reflectivity, controlled dispersion, and a thermally robust substrate are desired.